

# ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

<b>Title of Invention</b>	<b>METHOD FOR IMAGE REVERSAL OF IMPLANT RESIST USING A SINGLE PHOTOLITHOGRAPHY EXPOSURE AND STRUCTURES FORMED THEREBY</b>
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Application Number :

*10/209,285*

Confirmation Number:

First Named Applicant:

Steven Holmes

Attorney Docket Number:

FIS920030151US2

Art Unit:

*2826  
Quach*

Examiner:

Search string:

( 4564584 or 5266505 or 5306390 or 6015991 or 6221562 or 6309975 or 6358856 or 6372412 or 6448164 or 6489191 or 6503689 or 6562547 or 6559680 or 20020172896 ).pn

## US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
<i>TG</i>	1	4564584	1986-01-14	Fredericks et al.		430	312
<i>TG</i>	2	5266505	1993-11-30	Ahlgren et al.		437	31
<i>TG</i>	3	5306390	1994-04-26	Peek		156	659.1
<i>TG</i>	4	6015991	2000-01-18	Wheeler et al.		257	336
<i>TG</i>	5	6221562	2001-04-24	Boyd et al.	B1	430	314
<i>TG</i>	6	6309975	2001-10-30	Wu et al.	B1	438	705
<i>TG</i>	7	6358856	2002-03-19	Lyons et al.	B1	438	703
<i>TG</i>	8	6372412	2002-04-16	Hakey et al.	B1	430	325
<i>TG</i>	9	6448164	2002-09-10	Lyons et al.	B1	438	585
<i>TG</i>	10	6489191	2002-12-03	Shao et al.	B2	438	199
<i>TG</i>	11	6503689	2003-01-07	Zampinin et al.	B2	430	270.1
<i>TG</i>	12	6562547	2003-05-13	Kraft et al.	B2	430	314
<i>TG</i>	13	6559680	2003-07-29	Lin	B2	430	314

## US Published Applications

Note: Applicant is not required to submit a paper copy of cited US Published Applications

init	Cite.No.	Pub. No.	Date	Applicant	Kind	Class	Subclass
<i>TG</i>	1	20020172896	2002-11-21	Adams et al.	A1	430	322

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Signature

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1/31/05

Examiner Name

Date